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(71) Applicant: **CJ CHEILJEDANG CORPORATION**
[KR/KR]; 330, Dongho-ro, Jung-gu, Seoul 04560 (KR).

(72) Inventors: **KWON, Nara**; 330, Dongho-ro, Jung-gu, Seoul 04560 (KR). **BONG, Hyun-Ju**; 330, Dongho-ro, Jung-gu, Seoul 04560 (KR). **LEE, Ah Reum**; 330, Dongho-ro, Jung-gu, Seoul 04560 (KR). **HEO, Jung Ok**; 330, Dongho-ro, Jung-gu, Seoul 04560 (KR).

(74) Agent: **HANOL INTELLECTUAL PROPERTY AND LAW**; 6F, 135, Beobwon-ro, Songpagu, Seoul 05836 (KR).

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(54) Title: STRAIN FOR PRODUCING HIGH CONCENTRATION L-GLUTAMIC ACID AND METHOD FOR PRODUCING L-GLUTAMIC ACID USING THE SAME

(57) Abstract: The present application relates to a strain and a microorganism for producing high concentration L-glutamic acid and a method of use thereof.



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